

## EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	9265	semiconductor and wafer and (cluster\$3 integrated adj system)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/13 18:30
S2	4006	S1 not (@rlad>"20010405" @ad>"20010405")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/04/13 18:31
S3	195	S2 and (cmp polish\$3) and ((wet liquid) near5 etch\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/04/13 18:33
S4	4	S3 and ((wet liquid) near5 etch\$3) same (cluster\$3 integrated adj system)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/13 18:34
S5	195	S2 and (cmp polish\$3) and ((wet liquid) near5 etch\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/13 18:33
S6	4	S4 and ((wet liquid) near5 etch\$3) same (cluster\$3 integrated adj system)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/13 18:34